

# TCAD simulation II

E. Giulio Villani

# Overview

- **Simulation example of 2D PN junction using SDEVICE**
- **IV and CV**

# TCAD simulation SDEVICE

# TCAD Synopsys Simulation

- **Sentaurus Device** is a numeric semiconductor device simulator, capable of simulating the electrical, thermal, and optical characteristics of various semiconductor devices.
- It simulates 1D, 2D, and 3D device behaviour over a wide range of operating conditions, including mixed-mode circuit simulation, combining numerically simulated devices with their compact modeling, which is performed on a SPICE-based circuit simulation level.

1 **File Section:** input/output files

2 **Electrode Section:** electrode definition, matching those in the input grid

3 **Physics Section:** physics models to use in the simulation

4 **Plot Section:** variables to plot

5 **Math Section:** solvers






6 **Solve Section:** what to solve (IV,CV, Charge injection)

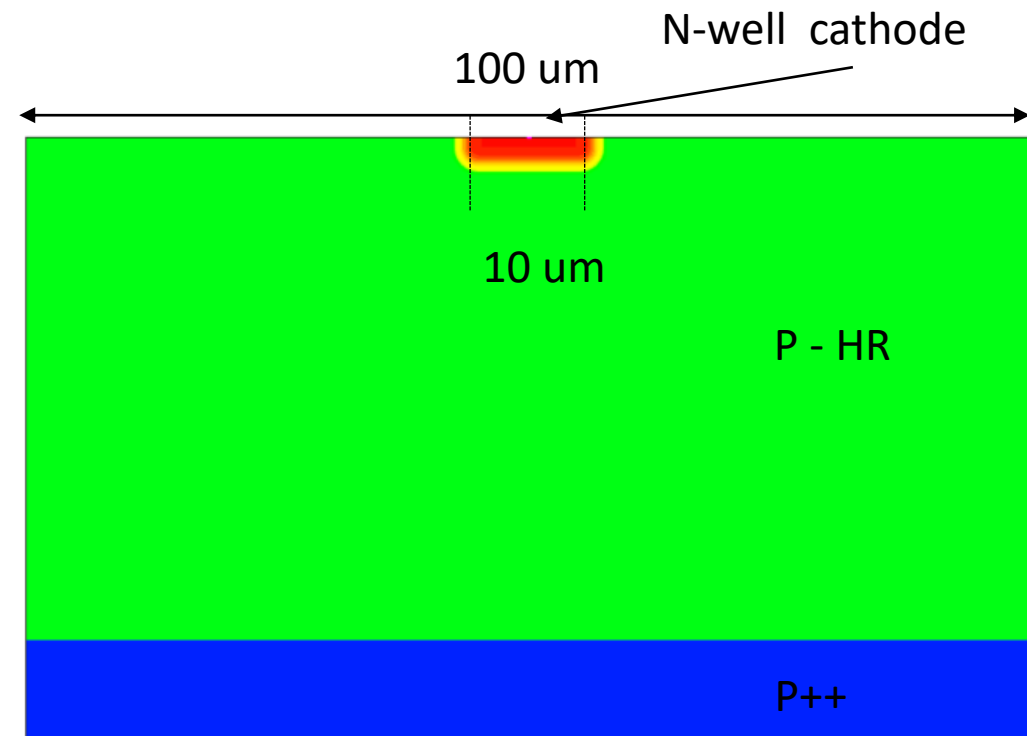
A typical command file of Sentaurus Device consists of several sections (or statement blocks), with each section executing a relatively independent function. The default extension of the command file is `_des.cmd`, for example, `pp1_des.cmd`. To start: **sdevice**



# TCAD Synopsys Simulation

- SDEVICE simulation of 2D pn junction
  - **IV**
  - **SC/Depletion region visualisation**
  - **Breakdown voltage**
- The DC analysis is performed by sweeping the voltage across the cathode, keeping the substrate contact grounded

				
TwoDsde	sdeviceV_REV	deviceV_FWD	deviceCV_RE	sdeviceCCE
	Temp			Vbias
	[n2] 280	[n6] --	[n9] --	[n15] --
				[n12] 100



# TCAD Synopsys Simulation

- SDEVICE command file:
  - **File Section:** input/output files
  - **Electrode Section:** electrode definition, matching those in the input grid

```
#####      2D PN junction DC bias analysis #####  
  
#define Vdd 1000.  
  
## Input and Output Files  
  
        File {  
  
        grid   = "2D_PNjct_msh.tdr"  
  
        }  
  
### Electrode definition  
  
        Electrode {  
  
##$ By default Ohmic contact  
        { Name="cathode" Voltage= 0.0  }  
  
###  
        { Name="cathode" Voltage= 0.0 Workfunction=4.5  }  
  
        { Name="substrate" Voltage= 0.0  }  
  
        }  
  
}
```

# TCAD Synopsys Simulation

- SDEVICE command file
  - **Physics Section:** physics models to use in the simulation
  - **Plot Section:** variables to plot

```
### Physics models
Physics {

    Fermi
    Temperature = @Temp@
    Mobility(
    DopingDep
    PhuMob Enormal (Lombardi PosInterfaceCharge)
    HighFieldSaturation(GradQuasiFermi)

    )

    Recombination(
    SRH( DopingDep TempDependence ElectricField
(Lifetime = Hurkx ) )
    Auger
    Avalanche(Okuto EParallel BandgapDependence )
    ##Avalanche(Unibo EParallel BandgapDependence )
    )
    EffectiveIntrinsicDensity(BandGapNarrowing
(OldSlotboom) )
    }

### Plots definition
Plot
{
    eDensity hDensity
    TotalCurrent/Vector eCurrent/Vector hCurrent/Vector ....
    eMobility hMobility....
}
}
```

# TCAD Synopsys Simulation

- SDEVICE command file
- **Math Section:** solvers to use

## ### Math definition

```
Math {  
  
    BreakCriteria{ Current(Contact="cathode" AbsVal=1e-6) }  
  
    extrapolate  
    digits= 4  
    ##ExtendedPrecision  
    numberOfThreads= maximum  
    Derivatives  
    Avalderivatives  
    RelErrControl  
  
    method=ILS  
    submethod=ILS  
    Iterations=20  
    Rhsmin      = 1e-20  
    ParallelToInterfaceInBoundaryLayer(FullLayer -ExternalBoundary)  
        GeometricDistances  
        eMobilityAveraging=ElementEdge  
        hMobilityAveraging=ElementEdge  
    ##AvalDensGradQF  
    ErrRef(electron)=1e8  
    ErrRef(hole)=1e8  
    RefDens_eParallel_ElectricField_HFS= 1e17  
    RefDens_hParallel_ElectricField_HFS= 1e17  
    RefDens_eParallel_ElectricField_Aval= 1e17  
    RefDens_hParallel_ElectricField_Aval= 1e17  
}
```



# TCAD Synopsys Simulation

- SDEVICE command file
  - **Solve Section:** what to solve (IV,CV, Charge injection...)

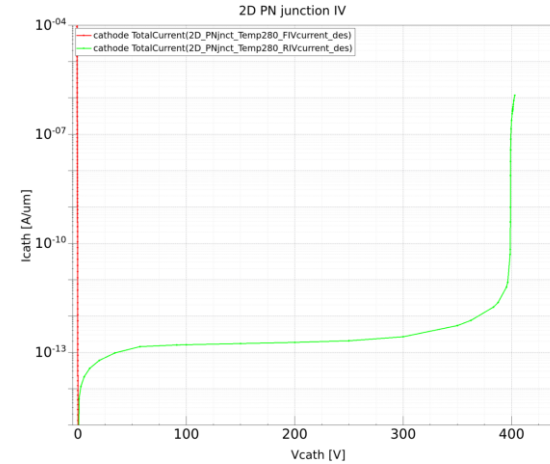
## ### Solve procedure

```
Solve {  
  
    Coupled(Iterations= 500 LineSearchDamping= 1e-4){ Poisson }  
    Coupled(Iterations= 50 LineSearchDamping= 1e-4){ Poisson Electron Hole }  
    Plot (FilePrefix = "2D_PNjct_Temp@Temp@_bias_OV")  
  
        NewCurrentPrefix="2D_PNjct_Temp@Temp@_RIV"  
  
            Quasistationary (  
                InitialStep=0.001 Increment=2.0 decrement=4.0  
                MaxStep=0.05 Minstep=1.e-15  
                Goal { name="cathode" Voltage= Vdd}  
            ) { Coupled { Poisson Electron  
                Hole }  
  
                Plot(FilePrefix="2D_PNjct_Temp@Temp@_RBias_" Time=(0.1;0.2;0.3;0.4;0.5)  
                NoOverWrite)  
                ### fixed plot interval  
                ### CurrentPlot( Time=(Range=(0 1) Intervals= 200  
                ) )  
            }  
        }  
    }  
}
```

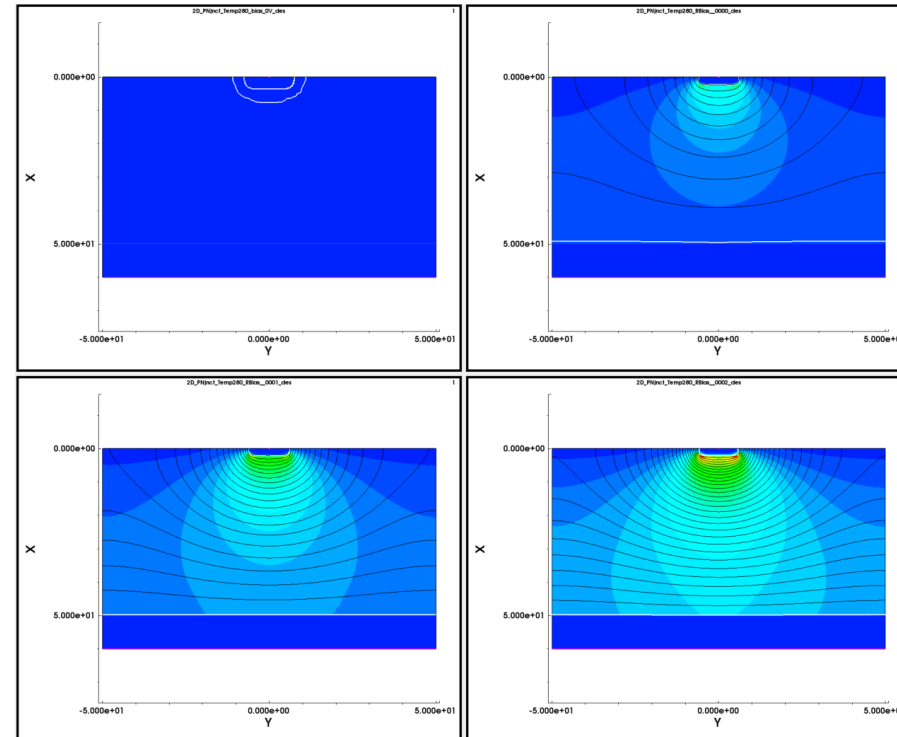
# TCAD Synopsys Simulation

- Visualize the resulting mesh using **SVISUAL**
  - Re-mesh the structure changing the p – doping
  - Visualise the meshing Investigate the extension of depletion vs. bias/doping/temperature

$$w = \sqrt{\frac{2\epsilon_s(N_A + N_D)}{e(N_A N_D)} (V_{bi} - V)}$$



FWD and REV IV @ 280 K vs. Vbias



Depletion and x-Field vs. Vbias

## TCAD and simulation I

---

# Thank you

giulio.villani@stfc.ac.uk

- Simulation example : 2D pn using SDEVICE
- IV (FWD/REV), SC, Depletion region